AUG 0 6 2001

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

BRUNNER ET AL-1

SERIAL NO.:

09/425,694 t

EXAMINER: C. BROWN

FILED:

OCTOBER 22, 1999

GROUP:

1765

TITLE:

PROCESS FOR THE WET CHEMICAL TREATMENT OF

SEMICONDUCTOR WAFERS

AMENDMENT IN RESPONSE TO NON-FINAL OFFICE ACTION

ATTN: BOX FEE AMENDMENT

Assistant Commissioner of Patents

Washington, D.C. 20231

Dear Sir:

In response to the Non-Final Office Action dated Mar 2001, with the time for reply having been extended for two months or until August 12, 2001, please amend the above-identified patent application as follows:

IN THE CLAIMS:

Please amend claim 1, and claim 11, as follows. A Marked-Up Version of these amended claims is attached hereto.

Claim 1 (Three Times Amended):

A process for the wet chemical treatment of semiconductor

R:\Marie\ERF\BRUNNER ET AL 1 NON FINAL AMNT.wpd